

U.S. Department of Commerce, Patent and Trademark Office				Atty Docket No.		Application No.	
				NEC0253US		Unassigned	
INFORMATION DISCLOSURE STATEMENT BY APPLICANT				Applicant(s)		10/695 285	
(Use several sheets if necessary)				John W. Jacobs and Elizabeth A. Dauch			
				Filing Date 10/28/03		Group 2813	
				Herewith		Unassigned	
U.S. Patent Documents							
*Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
JMS	AA	6,077,762	Jun. 20, 2000	Liang et al.	438	593	—
JMS	AB	6,153,531	Nov. 28, 2000	Bothra et al.	438	745	—
	AC						
	AD						
Foreign Patent Documents							
							Translation
		Document	Date	Country	Class	Subclass	Yes No
	AE						
	AF						
	AG						
	AH						
OTHER ART (Including Author, Title, Date, Pertinent Pages, Etc.)							
JMS	AI	Bothra, S., H. Sur and V. Liang, "A New Failure Mechanism by Corrosion of Tungsten in a Tungsten Plug Process," Technology Development, VLSI Technology, Inc., San Jose, California, 95131; 1998 IEEE.					
	AJ						
	AK						
	AL						
	AM						
	AN						
	AO						
	AP						
Examiner <i>John W. Jacobs</i>					Date Considered 3/2/05		
*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with your communication to applicant.							